

## THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: § Patent No.: 7074527 B2  
 LU, BING, et al. §

Application No.: 10/668432 § Issue Date: 07-11-2006

Filed: 09-23-2003 § Examiner: S. Rosasco

Docket No.: SC12878TP § Group Art Unit: 1756

Title: METHOD FOR FABRICATING A MASK USNG A HARDMASK AND METHOD FOR  
 MAKING A SEMICONDUCTOR DEVICE USING THE SAME

## Certificate of Submission

I hereby certify that this correspondence is being submitted to the USPTO,  
 Alexandria, VA.

Addressed per C.F.R. § 1.1(a) and deposited with the United States Postal  
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 EFS Web".

February 28, 2008  
 Date of Submission

Teresa Shephard  
 Signature

Teresa Shephard  
 Printed Name of Person Signing Certificate

Commissioner for Patents  
 Alexandria, VA 22313

SUBMISSION OF CERTIFICATE OF CORRECTION

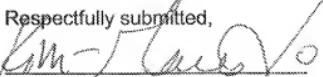
Dear Commissioner:

Enclosed is a Certificate of Correction listing error(s) in the subject patent.

Please enter these corrections. Since the errors appear to be on the part of the United  
 States Patent Office, there should be no charge.

2/28/08  
 Date

Respectfully submitted,

  
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CERTIFICATE OF CORRECTION**

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PATENT NO.: 7074527 B2  
APPLICATION NO: 10/668432  
DATE: 09-23-2003  
FIRST NAMED INVENTOR: LU, BING

It is certified that error appears in the above-identified patent and that said Letters Patent are hereby corrected as shown below:

In Column 7, Line 62, Claim No. 9:

Change "prises Forming the second hardmask" to --prises forming the second hardmask--

In Column 8, Line 20, Claim No. 14:

Change "comprises Penning the second hardmask" to --comprises forming the second hardmask--

In Column 8, Line 35, Claim No. 15:

Change "transferring the lint pattern from" to --transferring the first pattern from--

In Column 8, Line 59, Claim No. 20:

Change "wherein the Forming the" to --wherein the forming the--

MAILING ADDRESS OF SENDER (Please do not use customer number below)

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